| Search Notes | | | |
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| Application/Control No. | Applicant(s)/Patent under Reexamination | - |
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| 10/614,056 | ANDO, TAKESHI | |
| Examiner | Art Unit | |
| Chuck Huynh | 2617 | |

| SEARCHED | | | |
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| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | |
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